GEMStar XT-S/DP™ PEALD/Thermal ALD System



The GEMStar XT[™] platform is the industry's only true benchtop Atomic Layer Deposition (ALD) System, now more configurable to meet our Customer's needs and budgets

GEMStar XTTM family produces best in class ALD films from high aspect ratio particles through 200mm substrates both in single substrate and batch modes of operation

The GEMStar XT-DPTM Plasma Enhanced Atomic Layer Deposition (PEALD) system extends the capabilities of the GEMStar XTTM Thermal system to include best in class plasma processing through the full range of substrates.

Configured with a 300 Watt air cooled direct Inductively Coupled Plasma (ICP) RF system with four mass flow controlled gas inputs, either single (S) or dual (D) 200 °C manifold zones, four (S) or eight (D) high speed material ALD valve ports (one with vapor push technology), two locatable 200°C material temperature zones and an external gas interface, the **GEM**Star XT-DPTM system is a powerful plasma enabled tool to extend your research and processing requirements to the next level.

Some key features of the system include:

- 300-Watt Air Cooled Direct ICP Head with four metal sealed mass flow-controlled plasma gas inputs
- Adjustable reactor temperature up to 300°C
- Up to 200°C uniform gas distribution delivery
- ◆ Pulsed Vapor Push (PVP[™]) to handle very lowpressure material
- Substrate configurable end effectors up to 200 mm diameter substrates, as well as a 450°C heated platen option
- User selectable carrier gas MFC controlled input up to 200 SCCM
- ♦ Field proven GEMFlow[™] Control System



Ease of Operation

The Arradiance **GEM**Flow[™] Software provides complete user control over all key operating parameters such as temperature, gas flow rate, highspeed ALD valves, RF Power and vacuum isolation.

Preloaded on business level Windows[®] Laptop

User created processes can be saved enabling substrate to substrate and batch to batch consistency without sacrificing flexibility

- Diagnostic system and logging creates traceable data of all system parameters during operation
- Internal GEMStar XT USB control module

Safety

GEMStar XT Systems are designed to be SEMI S2 Compliant where applicable without sacrificing the needs of material research and development needs

- CE Compliant, CSA Optional
- Watchdog protection and EMO interface
- Operator touch safe exterior
- RGIPTM Reactor Gas Injection Protocol avoids accidental, unwanted, or unsafe chemical material reaction for all gas injection ports for simple and complex nanolaminate processes

Serviceability

Modular ergonomic design with top panel access to all critical components

- Fast precursor changes and reconfiguration
- Easy access power, vacuum and gas connections
- Perfectly suited for glove box configuration

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Specifications	
System Dimensions	Main - 25" H x 32" W x 24" D designed to fit on desktop, lab bench or glovebox
	Half Rack - 11"H x 12"W x 21"D for RF Power Supply
Door Mounted Substrate End	Specify end effector diameter at time of order (200 mm default, 150 mm, 100 mm)
Effector	Other sizes or batch cassettes available on request
Reactor/Door Thermal Zones	Two controllable zones up to 300 °C ± 1 °C Optional 450 °C Processing available on request
RF Plasma Source	300 W ICP Air Cooled Power adjustable head with automatic tuning
	Four mass flow controlled (MFC) plasma gas inputs with automatic pneumatic
	safety normally closed valves
Material Manifold	Single (S) or Dual (D) controllable manifold zone up to 200 °C
	Four (S) or Eight (D) High Speed ALD Valve Controlled Material Ports
	Single Pulsed Vapor Push (PVP [™]) Zone controlled by High Speed ALD Valve
Material Bottle Heated Zones	Up to four movable zones up to 200 °C
Material Bottles	Up to four or six (2 STD) DOT certified 150 ML Bottles with bellows sealed valves
External Gas Input	Main System - Up to 4 (2 STD) Inputs for external user selectable gasses
-	RF System – 4 inputs, 3 are user selectable for Plasma gas inputs
Inert Carrier Gas	Mass Flow Controlled up to 200 SCCM
Control System	GEMFlow [™] Control Software
	Windows [®] Professional 64-bit Laptop
	GEMStar XT [™] USB control module
RF Power Supply	11"H x 12"W x 21"D Half Rack
Metrology Port	Spare NF-40 In Line metrology port for QCM or other customer needs
Vacuum Gauge	Convection Vacuum Gauge
	Optional ALD Insensitive Capacitive Monometer Gauge
	Equipment Safety
Emergency Off	Standard DB9 port to support EMO or other safety shut down requirements
Touch Safe	All Exterior Components thermal and electrical
Watchdog	System shuts down to Safe mode if communication is lost with computer
Normally Closed Vales	All internal valves close when power removed
Certification	CE Marked
	Designed to comply with applicable SEMI S2 guidelines
	CSA optional on request
	Facilities Requirements
Carrier Gas	Ar 10-20 psig regulated VCR-4 Type Connection
Plasma Gases	Four 10-20 psig regulated VCR-4 Type Connection
	Note: System comes with above carrier gas also connected to PEALD MFC port 1
CDA (Clean Dry Air)	80 psig ± 5 psi regulated
AC Power	Main System – Dedicated 110-120 VAC 50/60 Hz 20A
	RF System – Separate Dedicated 110-120 VAC 50/60 Hz 20A
System Weight	< 275lbs including plasma system components
	KF 50 Vacuum Connection
Vacuum Pump (optional)	≥ 35 cfm Dry Pump